

Substitute for form 1449A/PTO (modified) INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use as many sheets as necessary) Page 2 of 5	Application Number	10/729073
	Filing Date	December 5, 2003
	First Named Inventor	DAMS, RUDOLF J.
	Art Unit	
	Examiner Name	
	Attorney Case Number	58809US002

U.S. Patent Documents					
Exam. Incl.*	Cite No.	Document Number	Publication Date or Issue Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
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*Examiner: /Rabon Sergeant/	Date Considered: 01/05/2007
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